

## Glass Thickness Compensation Ultra-violet Objective Lenses | PFL-UV-AG-LC



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PFL-UV-AG-LC series are objective lenses of which magnification cover 20X,50X and 80X. They can be used in a laser processing machines which is using 266nm and 532nm YAG pulse laser. Its glass-thickness- compensation optical design makes it possible to realize an ideal beam spot size and quality even if it was processed thorough a cover glass. These objective lenses will well match with a laser repair processing for LCD or OLED module.

- Two kinds objective lenses are available. They are designed to correct aberration depending on the thickness of cover glass.(t=0.7 mm and 1.1 mm)
- It is the long working infinity correction function that is used to introduce a laser system and coaxial observation.
- It is also used for the observation of ultra-violet light.
- Laser Damage Threshold(reference): 0.09 J/cm<sup>2</sup> (266nm), 0.2J/cm<sup>2</sup> (532nm)

(Laser pulse width: 10ns, repetition frequency: 20Hz)



### **Typical Transmittance Data** T: Transmission 100 80 60 20 PFL-20-UV-AG-LC-A PFL-50-UV-AG-LC-A PFI -80-UV-AG-LC 300 400 500 600 700 800 200 λ [nm]

### Guide

- Available fixed objective lens holder (LHO-26).
- WEB Reference Catalog Code W4024
- ▶When the objective lens is fixed to a 2 axis holder, please consult our Sales Division.
- For laser processing, we offer a dichoric block (DIMC) and for laser unit with coaxial illumination and observation (OUCI-2)

WEB Reference Catalog Code W2041, WEB Reference Catalog Code W2012

### Attention

- ▶When an objective lens is used in laser processing, use the diameter of the incident beam to extend to a size of half the pupil diameter (1/e2). A small light spot cannot be achieved when the incident beam is too narrow. Please note if there is a laser energy density increase, there will be a high possibility of damage to the objective lens.
- When the thickness of cover glass is not same as the specified, designed specifications may not be achieved due to aberration.
- ▶ Magnification is the value when using the imaging lens f=200mm. When used in a microscope lens barrel from other manufacturers there may be different magnifications. The actual magnification should be calculated from the ratio of the focal length of the objective lens and the focal length of the imaging lens to verify the focal length of the imaging lens barrel to be used.

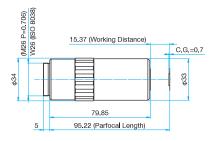
Specifications										
Part Number	Item name	Magnification		Numerical aperture NA	Working Distance W.D. [mm]		Focal depth (λ=550nm) [μm]		eld of view (Imaging device 1/2-inch) [mm]	Weight [kg]
PFL-20-UV-AG-LC07-A	LCD Plan UV 20x (t0.7)	20×	10	0.36	15.15	0.76	±2.1	φ1 <b>.</b> 2	0.24×0.32	0.35
PFL-20-UV-AG-LC11-A	LCD Plan UV 20x (t1.1)	20×	10	0.36	15.20	0.76	±2.1	φ1.2	0.24×0.32	0.35
PFL-50-UV-AG-LC07-A	LCD Plan UV 50x (t0.7)	50×	4	0.42	11.99	0.65	±1.6	φ0.48	0.10×0.13	0.40
PFL-50-UV-AG-LC11-A	LCD Plan UV 50x (t1.1)	50×	4	0.42	11.99	0.65	±1.6	φ0.48	0.10×0.13	0.40
PFL-80-UV-AG-LC07	LCD Plan UV 80x (t0.7)	80×	2 <b>.</b> 5	0.55	9.78	0.50	±0 <b>.</b> 9	φ0.3	0.06×0.08	0.30
PFL-80-UV-AG-LC11	LCD Plan UV 80x (t1.1)	80×	2.5	0.55	9.65	0.50	±0.9	φ0.3	0.06×0.08	0.35



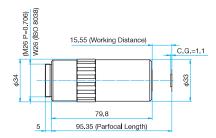


Outline Drawing (in mm)

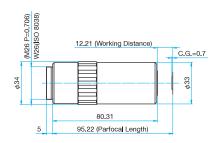
### PFL-20-UV-AG-LC07-A



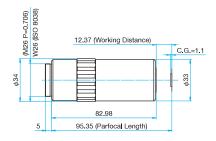
### PFL-20-UV-AG-LC11-A



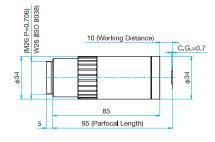
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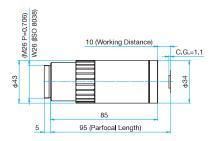
### PFL-50-UV-AG-LC11-A



### PFL-80-UV-AG-LC07



### PFL-80-UV-AG-LC11



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## Glass Thickness Compensation Near Ultra-violet Objective Lenses PAL-NUV-LC

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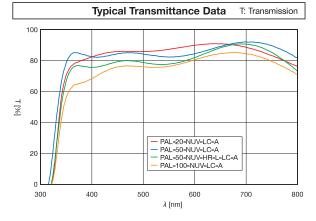
This objective lens can be used for laser machining using pulsed laser of THG (355nm) YAG laser. Its glass-thickness- compensation optical design makes it possible to realize an ideal beam spot

- Two kinds objective lenses are available. They are designed to correct aberration depending on the thickness of cover glass. (t= 0.7 mm and 1.1 mm)
- High resolution type (NA=0.65) is also available.
- With its long working infinity correction function; this objective lens can be used for a laser system and coaxial observation.
- This objective lens can be used with a pulse laser of visible light (532nm).
- Laser Damage Threshold(reference): 0.05 J/cm<sup>2</sup> (355nm), 0.1J/cm<sup>2</sup> (532nm)

size and quality even if it was processed thorough a cover glass.

(Laser pulse width: 10ns, repetition frequency: 20Hz)





### Guide

- Available fixed objective lens holder (LHO-26).
  - WEB Reference Catalog Code W4024
- ▶ When the objective lens is fixed to a 2 axis holder, please consult our Sales Division.
- For laser processing, we offer a dichoric block (DIMC) and for laser unit with coaxial illumination and observation (OUCI-2).

WEB Reference Catalog Code W2041, WEB Reference Catalog Code W2012

#### Attention

- When an objective lens is used in laser processing, use the diameter of the incident beam to extend to a size of half the pupil diameter (1/e<sup>2</sup>). A small light spot cannot be achieved when the incident beam is too narrow. Please note if there is a laser energy density increase, there will be a high possibility of damage to the objective lens.
- ▶When the thickness of cover glass is not same as the specified, designed specifications may not be achieved due to aberration.
- ▶ Magnification is the value when using the imaging lens f=200mm. When used in a microscope lens barrel from other manufacturers there may be different magnifications. The actual magnification should be calculated from the ratio of the focal length of the objective lens and the focal length of the imaging lens to verify the focal length of the imaging lens barrel to be used.

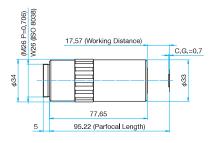
Specifications										
Part Number	Item name	Magnification	Focal length f [mm]				Focal depth (λ=550nm) [μm]		eld of view (Imaging device 1/2-inch) [mm]	Weight [kg]
PAL-20-NUV-LC07-A	LCD PlanApo NUV 20x (t0.7)	20×	10	0.40	17.35	0.69	±1.7	φ1 <b>.</b> 2	0.24×0.32	0.35
PAL-20-NUV-LC11-A	LCD PlanApo NUV 20x (t1.1)	20×	10	0.40	17.40	0.69	±1.7	φ1 <b>.</b> 2	0.24×0.32	0.35
PAL-50-NUV-LC07-A	LCD PlanApo NUV 50x (t0.7)	50×	4	0.45	15.05	0.61	±1.4	φ0.48	0.10×0.13	0.36
PAL-50-NUV-LC11-A	LCD PlanApo NUV 50x (t1.1)	50×	4	0.45	15.01	0.61	±1.4	φ0.48	0.10×0.13	0.36
PAL-50-NUV-HR-L-LC07-A	LCD PlanApo NUV HR 50x (t0.7)	50×	4	0.65	9.91	0.42	±0.7	φ0.48	0.10×0.13	0.51
PAL-50-NUV-HR-L-LC11-A	LCD PlanApo NUV HR 50x (t1.1)	50×	4	0.65	9,89	0.42	±0.7	φ0.48	0.10×0.13	0.51
PAL-100-NUV-LC07-A	LCD PlanApo NUV 100x (t0.7)	100×	2	0.50	15.00	0.48	±0.8	φ0.24	0.05×0.06	0.39
PAL-100-NUV-LC11-A	LCD PlanApo NUV 100x (t1.1)	100×	2	0.50	15.00	0.48	±0.8	φ0.24	0.05×0.06	0.39



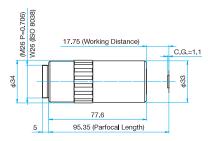


Outline Drawing (in mm)

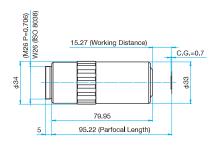
### PAL-20-NUV-LC07-A



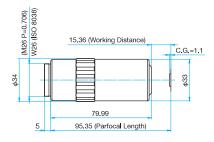
### PAL-20-NUV-LC11-A



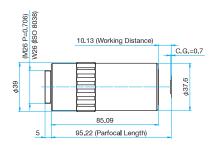
### PAL-50-NUV-LC07-A



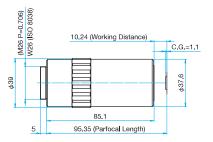
### PAL-50-NUV-LC11-A



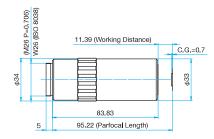
### PAL-50-NUV-HR-L-LC07-A



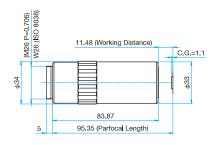
### PAL-50-NUV-HR-L-LC11-A



### PAL-100-NUV-LC07-A



### PAL-100-NUV-LC11-A



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# Glass Thickness Compensation Near Infrared Objective Lenses | PAL-NIR-LC | RoHS | W3465





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**Bio-photonics** 

This is a high NA infinity corrected objective lens for laser processing (femtosecond laser and fundamental of YAG laser). Its glass-thickness- compensation optical design makes it possible to realize an ideal beam spot size and quality even if it was processed thorough a cover glass.

- Two kinds objective lenses are available. They are designed to correct aberration depending on the thickness of cover glass. (t= 0.7 mm and 1.1 mm)
- With its long working infinity correction function; this objective lens can be used for a laser system and coaxial observation.
- It is also used for the observation of Near Infrared light.
- High resolution type (NA=0.65) is also available.
- This objective lens can be used with a pulse laser of visible light (532nm).
- Laser Damage Threshold(reference): 0.1J/cm² (532nm), 0.2 J/cm² (1064nm)

(Laser pulse width: 10ns, repetition frequency: 20Hz)



#### Guide

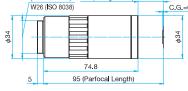
- Available fixed objective lens holder (LHO-26). WEB Reference Catalog Code W4024
- When the objective lens is fixed to a 2 axis holder, please consult our Sales Division.
- For laser processing, we offer a dichoric block (DIMC) and for laser unit with coaxial illumination and observation (OUCI-2) WEB Reference Catalog Code W2041, WEB Reference Catalog Code W2012

### Attention

- ▶ When an objective lens is used in laser processing, use the diameter of the incident beam to extend to a size of half the pupil diameter (1/e<sup>2</sup>). A small light spot cannot be achieved when the incident beam is too narrow, Please note if there is a laser energy density increase, there will be a high possibility of damage to the objective lens.
- ▶ When the thickness of cover glass is not same as the specified, designed specifications may not be achieved due to aberration.
- If the incident laser beam femtosecond is below 100fs, there is a possibility that the pulse width will spread,
- ▶ Magnification is the value when using the imaging lens f=200mm. When used in a microscope lens barrel from other manufacturers there may be different magnifications. The actual magnification should be calculated from the ratio of the focal length of the objective lens and the focal length of the imaging lens to verify the focal length of the imaging lens barrel to be used.

### **Outline Drawing**

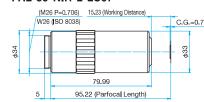
#### PAL-20-NIR-LC07 (M26 P=0.706) 20.2 (Working Distance) W26 (ISO 8038



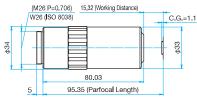
### PAL-20-NIR-LC11



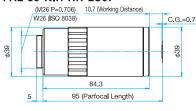
### PAL-50-NIR-L-LC07



### PAL-50-NIR-L-LC11



### PAL-50-NIR-HR-LC07



# **Typical Transmittance Data** 80 60 [%] PAL-20-NIR-LC PAL-50-NIR-L-LC PAL-50-NIR-HR-LC 400 λ [nm]

Specifications										
Part Number	Item name	Magnification	Focal length f [mm]				Focal depth (λ=550nm) [μm]		eld of view (Imaging device 1/2-inch) [mm]	Weight [kg]
PAL-20-NIR-LC07	LCD PlanApo NIR 10x (t0.7)	20×	10	0.40	19.98	0.69	±1.7	φ <b>1.</b> 7	0.24×0.32	0.36
PAL-20-NIR-LC11	LCD PlanApo NIR 20x (t0.7)	20×	10	0.40	19.85	0.69	±1.7	φ1.7	0.24×0.32	0.36
PAL-50-NIR-L-LC07	LCD PlanApo NIR HR 20x (t0,7)	50×	4	0.45	15.01	0.61	±1.4	φ0.46	0.10×0.13	0.34
PAL-50-NIR-L-LC11	LCD PlanApo NIR 50x (t0.7)	50×	4	0 <b>.</b> 45	14.97	0.61	±1.4	φ0.46	0.10×0.13	0.34
PAL-50-NIR-HR-LC07	LCD PlanApo NIR HR 50x (t0.7)	50×	4	0.67	10.48	0.41	±0.6	φ0.46	0.10×0.13	0.48



This is a high NA infinity corrected objective lens for laser processing (femtosecond laser). Its glass-thickness- compensation optical design makes it possible to realize an ideal beam spot size and quality even if it was processed thorough a cover glass.

- They are designed to correct aberration depending on the thickness of cover glass. (t=0.7mm)
- With its long working infinity correction function; this objective lens can be used for a laser system and coaxial observation.
- It is also used for the observation of Near Infrared light.
- This objective lens can be used with a pulse laser of visible light (532nm).
- Laser Damage Threshold(reference): 0.1/cm<sup>2</sup> (532nm), 0.15 J/cm<sup>2</sup> (780nm)

(Laser pulse width: 10ns, repetition frequency: 20Hz)



### Guide

- ▶ Available fixed objective lens holder (LHO-26). WEB Reference Catalog Code W4024
- ▶ When the objective lens is fixed to a 2 axis holder, please consult our Sales Division.
- For laser processing, we offer a dichoric block (DIMC) and for laser unit with coaxial illumination and observation (OUCI-2)

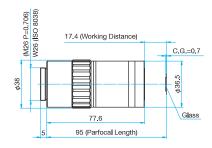
Catalog Code W2041, WEB Reference Catalog Code W2012

### Attention

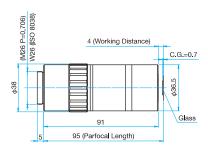
- ▶ When an objective lens is used in laser processing, use the diameter of the incident beam to extend to a size of half the pupil diameter  $(1/e^2)$ . A small light spot cannot be achieved when the incident beam is too narrow. Please note if there is a laser energy density increase, there will be a high possibility of damage to the objective lens.
- ▶ When the thickness of cover glass is not same as the specified, designed specifications may not be achieved due to aberration.
- ▶ If the incident laser beam femtosecond is below 100fs, there is a possibility that the pulse width will spread.
- ▶ Magnification is the value when using the imaging lens f=200mm. When used in a microscope lens barrel from other manufacturers there may be different magnifications. The actual magnification should be calculated from the ratio of the focal length of the objective lens and the focal length of the imaging lens to verify the focal length of the imaging lens barrel to be used.

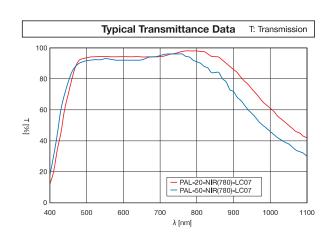
**Outline Drawing** 

### PAL-20-NIR(780)-LC07



### PAL-20-NIR(780)-LC07





Specifications										
Part Number	Item name	Magnification		Numerical aperture NA		Resolution (λ=550nm) [μm]			eld of view [Imaging device 1/2-inch) [mm]	Weight [kg]
PAL-20-NIR(780)-LC07	LCD PlanApo NIR(780) 20x (t0.7)	20×	10	0.45	17.2	0.6	±1.4	φ1.2	0.24×0.32	0.34
PAL-50-NIR(780)-LC07	LCD PlanApo NIR(780) 50x (t0.7)	50×	4	0.80	3.8	0.3	±0.4	$\phi$ 0.46	0.10×0.13	0.44

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## **Objective Lenses**

## **Others**

Infinity corrected objective lenses without glass thickness correction are available.

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3-Wavelengths Objective Lens | PFL-UV/NUV-AG



- For bright field observation and laser processing
- Infinity corrected Objective Lenses
- It can be used for 266nm / 355nm / 532nm
- Magnification 10x, 20x, 50x
- Air-Gap-type design for high power laser.
- Laser Damage Threshold (For reference only (Laser pulse width 10ns, repetition frequency 20Hz) 0.09 J/cm<sup>2</sup> (266nm), 0.1 J/cm<sup>2</sup> (355nm), 0.2 J/cm<sup>2</sup> (532nm)

### Ultra-violet Objective Lenses | PFL-UV-AG





- For bright field observation and laser processing
- Infinity corrected Objective Lenses
- It can be used for 266nm / 532nm
- Magnification 10x, 20x, 50x, 80x
- Air-Gap-type design for high power laser.
- Laser Damage Threshold (For reference only (Laser pulse width 10ns, repetition frequency 20Hz) 0.09 J/cm<sup>2</sup> (266nm), 0.2 J/cm<sup>2</sup> (532nm)

## Near Ultra-violet Objective Lenses | PAL-NUV





- For bright field observation and laser processing
- Infinity corrected Objective Lenses
- It can be used for 355nm
- Magnification 20x, 50x, 100x
- Plan-Apochromat design.
- Laser Damage Threshold (For reference only (Laser pulse width 10ns, repetition frequency 20Hz) 0.05 J/cm<sup>2</sup> (355nm), 0.1 J/cm<sup>2</sup> (532nm)

### Infrared (NIR) Objective Lenses | PAL-NIR





- For bright field observation and laser processing
- Infinity corrected Objective Lenses
- It can be used for 770nm 790nm / 1064nm
- Magnification 10x, 20x, 50x
- Plan-Apochromat design.
- Laser Damage Threshold (For reference only (Laser pulse width 10ns, repetition frequency 20Hz) 0.1 J/cm<sup>2</sup> (532nm), 0.2 J/cm<sup>2</sup> (1064 nm)

### Long Working Distance Objective Lenses | EPL/EPLE





- For bright field observation
- Infinity corrected Objective Lenses
- Parfocal Length 45mm
- Compatible with visible wavelength
- Plan-Achromat design.
- Magnification 5x, 10x,20x, 50x, 100x



# Contact sheet





### **Contact sheet for Custom-made Objective Lenses**

Estimation Order

Date

☐ To: Sig	ma Koki	Co., L	td.	FAX	+81-3	-5	638-	6550		
Affiliation (Organization Name)										
Department					Name					
TEL			FAX				E-mail			
Country/Address										
Name & Designation								(Ter	ntative nar	ne is okay)
Drawing Number					Estimate		Yes: by	Date		□No
Desired Delivery Date					Budget					JP Yen
Intention Please fill in as c possible.	oncrete as									
Design wave	elength								nm	
Focal length	1								mm	
Acceptance	angle								0	
Magnification	on									
NA										
Distortion										
Telecentric					☐ YES(θ	<	°)	□ NO		
Object - Ima	ge Distance								mm	
Working dis	tance W.D.								mm	
Flange back	(								mm	
Spot Size (1	/e²)								μm	
Resolution									μm	
Real field of (Imaging device)	View				mm,(				inch)	
Mounting sc	rew thread				mm,				mm	Pitch
External dim	nensions								mm	
Adjustable o	diaphragm			Requi	rement			☐Not requirement		
Coaxial illun	nination			Requi	rement			☐Not requirement		
	Divergence angle									
	Beam size								mm	
Specifications	$M^2$									
of Light						٧	V			
Source Used	Power or						J			
	Energy	Pulse v	vidth			5	3			
		Repetit	ion frequ	iency		Н	łz			

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Laser Processing

Sigma Koki Co., Ltd.



This objective lens can be used for laser machining using pulsed laser of SHG (532nm), THG (355nm), and FHG (266nm) YAG laser. Objective lense provides high transmittance at three harmonic wavelengths of YAG.

- With its long working distance and corrected field curvature, its natural observation image is obtained to the periphery of viewing the field.
- It is the long working infinity correction function that is used to introduce a laser system and coaxial observation.
- It allows observation of the sample with visible light (400 500nm).
- Laser Damage Threshold (Typical) 0.09 J/cm² (266nm), 0.1J/cm² (355nm), 0.2J/cm² (532nm) (Laser pulse width 10ns, repetition frequency 20Hz)



### Guide

- ▶ Available fixed objective lens holder (LHO-26). WEB Reference Catalog Code W4024
- ▶ When the objective lens is fixed to a 2 axis holder, please consult our Sales Division.
- For laser processing, we offer a dichoric block (DIMC) and for laser unit with coaxial illumination and observation (OUCI-2).

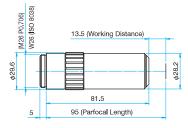
WEB Reference Catalog Code W2041

### Attention

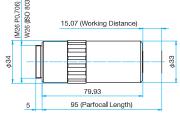
- ▶When an objective lens is used in laser processing, use the diameter of the incident beam to extend to a size of half the pupil diameter (1/e²). A small light spot cannot be achieved when the incident beam is too narrow. Please note if there is a laser energy density increase, there will be a high possibility of damage to the objective lens.
- ▶ The surface of an objective lens can be contaminated by debris during processing. To avoid this, please have sufficient working distance (WD) and insert a thin protective glass on the objective.
- ▶ Magnification is the value when using the imaging lens f=200mm. When used in a microscope lens barrel from other manufacturers there may be different magnifications. The actual magnification should be calculated from the ratio of the focal length of the objective lens and the focal length of the imaging lens to verify the focal length of the imaging lens barrel to be used.

**Outline Drawing** 

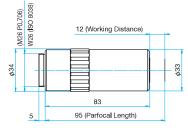
### PFL-10-UV/NUV-AG



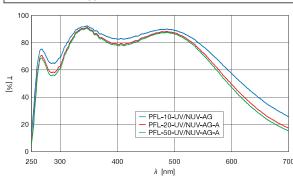
## PFL-20-UV/NUV-AG-A



### PFL-50-UV/NUV-AG-A



#### Typical Transmittance Data T: Transmission



Specifications										
Part Number	Item name	Magnifi- cation	Focal length f [mm]	Numerical aperture NA	Working distance WD [mm]	Resolution (λ=550nm) [μm]	Focal depth (λ=550nm) [μm]	Real fi (Eyepiece φ24mm) [mm]	ield of view (Imaging device 1/2-inch) [mm]	Weight [kg]
PFL-10-UV/NUV-AG	MPIan UV/NUV 10x	10x	20	0.20	13.5	1.40	±6.9	φ2.4	0.48×0.64	0.30
PFL-20-UV/NUV-AG-A	MPlan UV/NUV 20x	20x	10	0.36	15.07	0.76	±2.1	φ1.2	0.24×0.32	0.35
PFL-50-UV/NUV-AG-A	MPlan UV/NUV 50x	50x	4	0.42	12.0	0.65	±1.6	φ0.48	0.10×0.13	0.41

Compatible Optic Mounts

LHO-26

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## Ultra-violet Objective Lenses | PFL-UV-AG



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This objective lens can be used for laser machining using pulsed laser of SHG (532nm) YAG laser and FHG (266nm) YAG. Chromatic aberration is suppressed in both the visible and UV laser wavelength, achieving a high transmittance.

- With its long working distance and field curvature corrected, its natural observation image is obtained to the periphery of the visual field.
- It is the long working infinity correction function that is used to introduce a laser system and coaxial observation.
- It is also used for the observation of ultra-violet light.
- Laser Damage Threshold (Typical) 0.09 J/cm² (266nm), 0.2J/cm² (532nm)

(Laser pulse width 10ns, repetition frequency 20Hz)



#### Guide

- Available fixed objective lens holder (LHO-26).
  - WEB Reference Catalog Code W4024
- ▶ When the objective lens is fixed to a 2 axis holder, please consult our Sales Division.
- For laser processing, we offer a dichoric block (DIMC) and for laser unit with coaxial illumination and observation (OUCI-2).

WEB Reference Catalog Code W2041

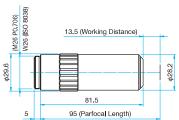
### Attention

- ▶ When an objective lens is used in laser processing, use the diameter of the incident beam to extend to a size of half the pupil diameter (1/e²). A small light spot cannot be achieved when the incident beam is too narrow. Please note if there is a laser energy density increase, there will be a high possibility of damage to the objective lens.

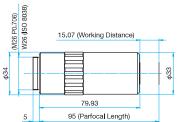
  The surface of an objective lens can be contaminated by debris
- during processing. To avoid this, please have sufficient working distance (WD) and insert a thin protective glass on the objective.
- ▶ Magnification is the value when using the imaging lens f=200mm. When used in a microscope lens barrel from other manufacturers there may be different magnifications. The actual magnification should be calculated from the ratio of the focal length of the objective lens and the focal length of the imaging lens to verify the focal length of the imaging lens barrel to be used.

### **Outline Drawing**

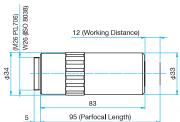
### PFL-10-UV-AG



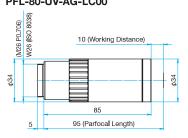
### PFL-20-UV-AG-A



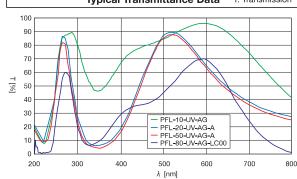
### PFL-50-UV-AG-A



## PFL-80-UV-AG-LC00



### Typical Transmittance Data T: Transmission



Specifications										
Part Number	Item name	Magnifi- cation	Focal length f [mm]	Numerical aperture NA	Working distance WD [mm]	Resolution (λ=550nm) [μm]	Focal depth (λ=550nm) [μm]	Real fi (Eyepiece φ24mm) [mm]	eld of view (Imaging device 1/2-inch) [mm]	Weight [kg]
PFL-10-UV-AG	MPlan UV 10x	10x	20	0.20	13.5	1.4	±6.9	φ2.4	0.48×0.64	0.30
PFL-20-UV-AG-A	MPlan UV 20x	20x	10	0.36	15.07	0.76	±2.1	φ1.2	0.24×0.32	0.35
PFL-50-UV-AG-A	MPlan UV 50x	50x	4	0.42	12.0	0.65	±1.6	φ0.48	0.10×0.13	0.41
PFL-80-UV-AG-LC00	MPlan UV 80x	80x	2.5	0.55	10.0	0.50	±0.9	$\phi$ 0.30	0.06×0.18	0.35

### Compatible Optic Mounts

I HO-26



This objective lens can be used for laser machining using pulsed laser of THG (355nm) YAG laser. Chromatic aberration is suppressed in both the visible and UV laser wavelength, achieving a high transmittance.

- With its long working distance and field curvature corrected, its natural observation image is obtained to the periphery of the visual field.
- With its long working infinity correction function; this objective lens can be used for a laser system and coaxial observation.
- It is also used for the observation of near ultra-violet light.
- This objective lens can be used with a pulse laser of visible light (532nm).
- Laser Damage Threshold (Typical) 0.05J/cm<sup>2</sup> (355nm), 0.1J/cm<sup>2</sup> (532nm)

(Laser pulse width 10ns, repetition frequency 20Hz)



### Guide

- ▶ Available fixed objective lens holder (LHO-26). WEB Reference Catalog Code W4024
- ▶ When the objective lens is fixed to a 2 axis holder, please consult our
- For laser processing, we offer a dichoric block (DIMC) and for laser unit with coaxial illumination and observation (OUCI-2).

ce Catalog Code W2041

### Attention

- ▶ When an objective lens is used in laser processing, use the diameter of the incident beam to extend to a size of half the pupil diameter (1/e²). A small light spot cannot be achieved when the incident beam is too narrow. Please note if there is a laser energy density increase, there will be a high possibility of damage to the objective lens.

  The surface of an objective lens can be contaminated by debris
- during processing. To avoid this, please have sufficient working distance (WD) and insert a thin protective glass on the objective.

  Magnification is the value when using the imaging lens f=200mm.
  - When used in a microscope lens barrel from other manufacturers there may be different magnifications. The actual magnification should be calculated from the ratio of the focal length of the objective lens and the focal length of the imaging lens to verify the focal length of the imaging lens barrel to be used.

**Outline Drawing** PAL-20-NUV-A PAL-50-NUV-A PAL-50-NUV-HR-L (ISO 8038) (M26 P0.706) (M26 P0.706) OSI W26 (ISO 17.25 (Working Distance) 15.1 (Working Distance) 10 (Working Distance) W26 (M26 W26 φ33 \$33 ¢36 77.75 79.9 95 (Parfocal Length) 95 (Parfocal Length) 95 (Parfocal Length) PAL-100-NUV-HR PAL-100-NUV-A Typical Transmittance Data T: Transmission 100 (M26 P0.706) (M26 P0.706) 90 W26 (ISO (80 10 (Working Distance) 80 11.23(Working Distance) W26 70 60 φ33 ф34 [%] 50 PAL-20-NUV-A 40

Specifications										
Part Number	Item name	Magnifi- cation	Focal length f [mm]	Numerical aperture NA	Working distance WD [mm]	Resolution (λ=550nm) [μm]	Focal depth (λ=550nm) [μm]	Real f (Eyepiece \$\phi 24mm) [mm]	ield of view (Imaging device 1/2-inch) [mm]	Weight [kg]
PAL-20-NUV-A	MPlanApo NUV 20x	20x	10	0.40	17.25	0.69	±1.7	φ1.2	0.24×0.32	0.35
PAL-50-NUV-A	MPlanApo NUV 50x	50x	4	0.45	15.1	0.61	±1.4	$\phi$ 0.48	0.10×0.13	0.36
PAL-50-NUV-HR-L	MPlanApo NUV HR 50x	50x	4	0.65	10.0	0.42	±0.65	φ0.48	0.10×0.13	0.51
PAL-100-NUV-A	MPlanApo NUV 100x	100x	2	0.57	11.23	0.48	±0.8	φ0.24	0.05×0.06	0.38
PAL-100-NUV-HR	MPlanApo NUV HR 100x	100x	2	0.70	10.0	0.39	±0.6	φ0.24	0.05×0.06	0.53

83.77

95 (Parfocal Length)

30

20

10

300

400

500

600

λ [nm]

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95 (Parfocal Length)

LHO-26

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PAI -100-NUV-A

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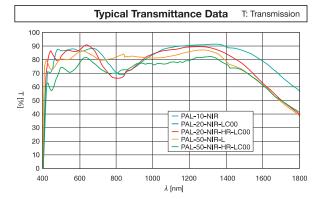
Others

## Infrared (NIR) Objective Lenses | PAL-NI

This is a high NA infinity corrected objective lens for laser processing (femtosecond laser and fundamental of YAG laser). You can also observe the laser beam coaxially with a laser processed surface that is designed to reduce the aberration of the visible wavelength.

- With its long working distance and field curvature corrected, its natural observation image is obtained to the periphery of the visual field.
- It is the long working infinity correction function that is used to introduce a laser system and coaxial observation.
- It is also used for the observation of infrared light.
- PAL-20-NIR-LC00/PAL-20-NIR-HR-LC00/PAL-50-NIR-HR-LC00 include protective glass unit (t=1.8mm). The protective glass will help protect the objective lens from debris spattering and scattered by laser processing. The protective glass unit can be replaced.
- These variety of objective lens can be used with a pulse laser of visible light such as 532nm. The damage threshold of each lens is 0.1J/cm² at 532nm, 0.2J/cm² at 1064nm (reference). (Laser pulse width 10nSec, repetition frequency 20Hz)





### Guide

- Available fixed objective lens holder (LHO-26).
  - WEB Reference Catalog Code W4024
- ▶When the objective lens is fixed to a 2 axis holder, please consult our Sales Division.
- ► For laser processing, we offer a dichoric block (DIMC) and for laser unit with coaxial illumination and observation (OUCI-2).

   WES Reference Catalog Code W2041

## Attention

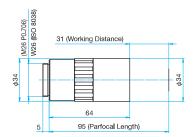
- ▶When an objective lens is used in laser processing, use the diameter of the incident beam to extend to a size of half the pupil diameter (1/e²). A small light spot cannot be achieved when the incident beam is too narrow. Please note if there is a laser energy density increase, there will be a high possibility of damage to the objective lens.
- ▶ The surface of an objective lens can be contaminated by debris during processing. To avoid this, please have sufficient working distance (WD) and insert a thin protective glass on the objective.
- If the incident laser beam femtosecond is below 100fs, there is a possibility that the pulse width will spread.
- ▶ Magnification is the value when using the imaging lens f=200mm. When used in a microscope lens barrel from other manufacturers there may be different magnifications. The actual magnification should be calculated from the ratio of the focal length of the objective lens and the focal length of the imaging lens to verify the focal length of the imaging lens barrel to be used.
- ▶ PAL-20-NIR-HR-LC00/PAL-50-NIR-HR-LC00 is designed in consideration of the thickness of including protective glass. If user removes the protective glass, the objective will not meet the performance specifications noted.

Specifications										
Part Number	Item name	Magnifi- cation	Focal length f [mm]	Numerical aperture NA	Working distance WD [mm]	Resolution (λ=550nm) [μm]	Focal depth (λ=550nm) [μm]	Real for (Eyepiece $\phi$ 24mm) [mm]	eld of view (Imaging device 1/2-inch) [mm]	Weight [kg]
PAL-10-NIR	MPlanApo NIR 10x	10x	20	0.30	31.0	0.92	±3.1	φ2.4	0.48×0.64	0.30
PAL-20-NIR-LC00	MPlanApo NIR 20x	20x	10	0.40	20.2	0.69	±1.7	φ1.2	0.24×0.32	0.36
PAL-20-NIR-HR-LC00	MPlanApo NIR HR 20x	20x	10	0.45	20.0	0.61	±1.4	φ1.2	0.24×0.32	0.42
PAL-50-NIR-L	MPlanApo NIR 50x	50x	4	0.45	15.1	0.61	±1.4	φ0.48	0.10×0.13	0.34
PAL-50-NIR-HR-LC00	MPlanApo NIR HR 50x	50x	4	0.67	10.0	0.41	±0.61	φ0.48	0.10×0.13	0.48

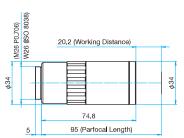


Outline Drawing (in mm)

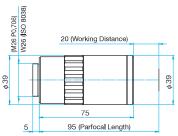
### PAL-10-NIR



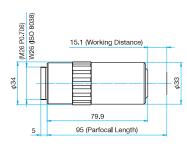
### PAL-20-NIR-LC00



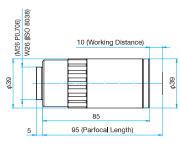
### PAL-20-NIR-HR-LC00



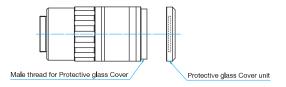
### PAL-50-NIR-L



### PAL-50-NIR-HR-LC00



How to replace the protective glass unit of PAL-20-NIR-HR-LC00/PAL-50-NIR-HR-LC00



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# Long Working Distance Objective Lenses | EPL/EPLE





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With its long working infinity correction function; this objective lens can be used for a laser system and coaxial observation.

The objective will allow user to focus a visible laser or microscopic observation of objects from a distance.

- Chromatic aberration is corrected in the visible range (400 700nm).
- Two types of parfocal distance are available, 45mm and 90mm.
- This parfocal 95mm lens has a long working distance and a corrected field curvature. Its natural observation image is obtained to the periphery of the visual field.
- It is possible to improve the response speed in the driving mechanism of the 45mm parfocal objective lens (SFS-OBL/ SFAI-OBL); with a lightweight auto focusing solution.

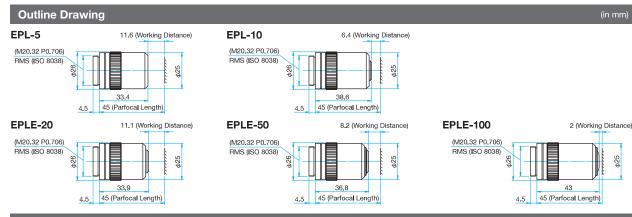


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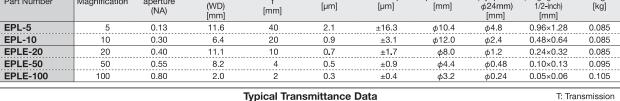
- ▶ Available fixed objective lens holder (LHO-20.32). Catalog Code W4024
- When the objective lens is fixed to a 2 axis holder, please consult our
- For laser processing, we offer a dichoric block (DIMC) and for laser unit with coaxial illumination and observation (OUCI-2). WEB Reference Catalog Code W2041

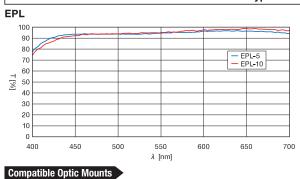
### Attention

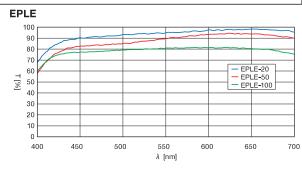
- ▶ When an objective lens is used in laser processing, use the diameter of the incident beam to extend to a size of half the pupil diameter (1/e2). A small light spot cannot be achieved when the incident beam is too narrow Please note if there is a laser energy density increase, there will be a high possibility of damage to the objective lens.
- The surface of an objective lens can be contaminated by debris during processing. To avoid this, please have sufficient working distance (WD) and insert a thin protective glass on the objective.
- ▶ Magnification is the value when using the imaging lens f=200mm. When used in a microscope lens barrel from other manufacturers there may be different magnifications. The actual magnification should be calculated from the ratio of the focal length of the objective lens and the focal length of the imaging lens to verify the focal length of the imaging lens barrel to be used.



Specificatio	ns									
Part Number	Magnification	Numerical aperture (NA)	Working distance (WD) [mm]	Focal length f [mm]	Resolution [µm]	Focal depth [µm]	Pupil diameter [mm]	Real fie (Eyepiece \$\phi 24mm) [mm]	eld of view (Imaging device 1/2-inch) [mm]	Weight [kg]
EPL-5	5	0.13	11.6	40	2.1	±16.3	φ10.4	φ4.8	0.96×1.28	0.085
EPL-10	10	0.30	6.4	20	0.9	±3.1	φ12.0	φ2.4	0.48×0.64	0.085
EPLE-20	20	0.40	11.1	10	0.7	±1.7	φ8.0	φ1.2	0.24×0.32	0.085
EPLE-50	50	0.55	8.2	4	0.5	±0.9	φ4.4	φ0.48	0.10×0.13	0.095
EPLE-100	100	0.80	2.0	2	0.3	±0.4	φ3.2	φ0.24	0.05×0.06	0.105







I HO-26



The long working distance objective lens infinity correction function and par focal length 95mm can be used for a laser system and coaxial observation. The objective will allow user to focus a visible laser or microscopic observation of objects from a distance.

- Chromatic aberration is corrected in the visible range (400 700nm).
- PAL/PAL-L has a long working distance and a corrected field curvature. Its natural observation image is obtained to the periphery of the visual field.



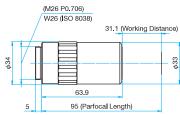
### Guide

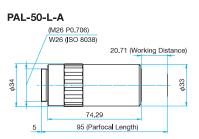
- Available fixed objective lens holder (LHO-26). WEB Reference Catalog Code W4024
- When the objective lens is fixed to a 2 axis holder, please consult our Sales Division.
- For laser processing, we offer a dichoric block (DIMC) and for laser unit with coaxial illumination and observation (OUCI-2). WEB Reference Catalog Code W2041

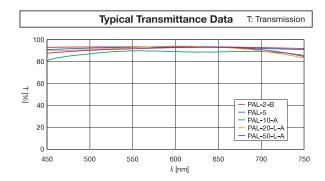
### Attention

- $\blacktriangleright$  When an objective lens is used in laser processing, use the diameter of the incident beam to extend to a size of half the pupil diameter (1/e2). A small light spot cannot be achieved when the incident beam is too narrow. Please note if there is a laser energy density increase, there will be a high possibility of damage to the objective lens.
- The surface of an objective lens can be contaminated by debris during processing. To avoid this, please have sufficient working distance (WD) and insert a thin protective glass on the objective.
- ▶ Magnification is the value when using the imaging lens f=200mm. When used in a microscope lens barrel from other manufacturers there may be different magnifications. The actual magnification should be calculated from the ratio of the focal length of the objective lens and the focal length of the imaging lens to verify the focal length of the imaging lens barrel to be used.

**Outline Drawing** PAL-5 PAL-2-B PAL-10-A (M26 P0 706) (M26 P0 706) M26 P0 706) W26 (ISO 8038) W26 (ISO 8038) W26 (ISO 8038 34 (Working Distance) 34 (Working Distance) 41 (Working Distance) φ32.2 60 54 95 (Parfocal Length) 95 (Parfocal Length) 95 (Parfocal Length) PAL-20-L-A (M26 P0 706)







Specifications										
Part Number	Item name	Magnifi- cation	Focal length f [mm]	Numerical aperture NA	Working distance WD [mm]	Resolution (λ=550nm) [μm]	Focal depth (λ=550nm) [μm]	Real f (Eyepiece \$\phi 24mm) [mm]	ield of view (Imaging device 1/2-inch) [mm]	Weight [kg]
PAL-2-B	MPlanApo 2x	2x	100	0.055	34.0	5	91	φ12	2.4×3.2	0.25
PAL-5	MPlanApo 5x	5x	40	0.14	41.0	2	14	φ4.8	0.96×1.28	0.24
PAL-10-A	MPlanApo 10x	10x	20	0.3	34.0	0.92	3.1	φ2.4	0.48×0.64	0.24
PAL-20-L-A	MPlanApo SL20x	20x	10	0.3	31.1	0.92	3.1	φ1.2	0.24×0.32	0.28
PAL-50-L-A	MPlanApo SL50x	50x	4	0.42	20.7	0.65	1.6	$\phi$ 0.48	0.10×0.13	0.31

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# **Microscope Objectives**

Catalog W3085

RoHS

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Others

These objectives are educational microscope objectives. They are to the JIS standard (Japanese Industry Standard), have Short focal length, high NA and are fit for beam divergent use.

- Full color correction throughout the visible wavelength.
- The OBL-40 and OBL-60 have a built-in spring in the tip of the objective lens.
- These objective lenses are finite.
- To mount it to a microscope, a finite 160mm adaptor is required.
- The distance from the attachment face of the objective lens to the image is 150mm.



#### Guide

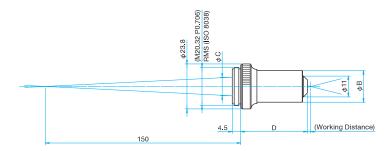
- ▶ Use a special filter (SFB) to correct the wave front distortion. WEB Reference Catalog Code W4036
- ▶ Objective holder (LHO) is available for these objective lenses. WEB Reference Catalog Code W4024
- Cross holder (TAT) is now available.

WEB Reference Catalog Code W4038

#### Attention

- ▶ Do not use objectives with high power laser.
- The objective lenses are finite and are not to be used with infinite lens barrel or poor images will result.
- To be used only in the visible wavelength range.

**Outline Drawing** 



Specification	s							
Part Number	Magnification	Length D [mm]	Barrel diameter $\phi$ B [mm]	Pupil diameter φC [mm]	Focal length f [mm]	NA	Working distance (WD) [mm]	Weight [kg]
OBL-10	10	30.5	φ16.7	φ8.3	16.6	0.25	5.5	0.05
OBL-20	20	35.2	φ16.7	φ7.1	9.0	0.40	1.7	0.05
OBL-40	40	36.4	φ19.7	φ5.8	4.5	0.65	0.6	0.06
OBL-60	60	36.7	φ19.7	φ4.9	2.91	0.85	0.3	0.07

Compatible Optic Mounts

LHO-20.32, -20.32A / TAT-18OA + TAT16RO

## Reflective Microscope Objectives Lenses







These reflective Microscope objective lenses are optimized for chromatic aberration over a bandwidth of 350nm to 7um. They are mainly used in microscope-spectrometry and failure analysis in the semiconductor industry.

- Adjustable for use with various types of microscope tubes with focal length ranging from 80mm to infinite
- The reflection mirror is strengthened with aluminium coating and MgF₂ protective layer.
- The RMS(M20.32 P0.706) mounting thread conforms to JIS standard and is compatible with all major microscope tubes.
- The focus point and image size of visible, UV and IR wavelengths shows no difference and precise matching of the images is possible.



#### Guide

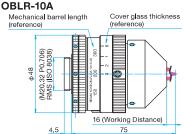
- ▶ There is no protective layer in aluminium coating for the vacuum ultra-violet spectrum and gold layer coating for near infrared is available as an option.
- ▶ An adapter for the objective lens turret is available (OBRLR-AMT). Check with our International Sales Division or your microscope manufacturer for compatibility and the use of reflective microscope objective lenses.
- ► Specific holder for microscope objective lenses (LHO-20.32) is available. ► WES Reference Catalog Code W4024

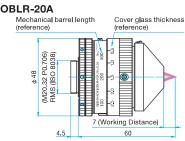
#### Attention

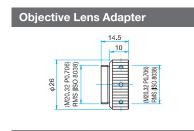
- ▶ These objectives are not to be used for laser processing due to light axis shielding of the reflective mirror.
- ▶There are microscopes that cannot be used with a turret.
- ▶ The cover glass is not mobile. Use the adjustable correction collar to adjust the focal length and the cover glass thickness.
- ▶ The center reflective mirror shields the center of the light axis. For direct light experiments, a low intense light in the center is expected.
- ▶ The light intensity loss if expected to be around 45%. (The center mirror shielding 36% and the aluminum reflectivity 90%)

Part Number

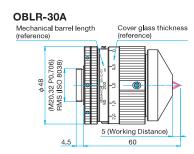


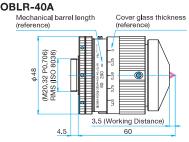






**OBLR-AMT** 





200 ° NS	Maintenance
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Specifications										
Part Number	Magnification	Wavelength Range	Focal length f [mm]	Numerical aperture (NA)	Field of view [mm]	Working distance (WD) [mm]	Mechanical tube length [mm]	Shielding ratio [%]		
OBLR-10A	10	350nm <b>–</b> 7μm	19.9	0.2	φ1.0	16	80 - ∞ (Variable)	about 36		
OBLR-20A	20	350nm – 7μm	10.0	0.35	$\phi$ 0.5	7	80 – ∞ (Variable)	about 36		
OBLR-30A	30	350nm – 7µm	6.7	0.41	φ0.34	5	80 – ∞ (Variable)	about 36		
OBLR-40A	40	350nm – 7µm	5.0	0.49	φ0.25	3.5	80 – ∞ (Variable)	about 36		

### Compatible Optic Mounts

LHO-20.32

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## Glass Thickness Corrected Objective Lenses

You can check our WEB catalog for the objective lenses that are not listed in the catalog.

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Others

## Glass Thickness Corrected Ultra-violet Objective Lenses | PFL-UV-AG-LC



• For bright field observation and laser processing

• Infinity corrected objective lens

• It can be used for 266nm/532nm.

• Glass thickness is corrected to t=0.7mm or 1.1mm.

• magnification 20x,50x,80x

• Air Gap type compatible with high-energy

Laser Damage Threshold (For reference only)
 (Laser pulse width 10ns, repetition frequency 20Hz)
 0.09 J/cm² (266nm)
 0.2J/cm² (532nm)

## Glass Thickness Corrected Near Ultra-violet Objective Lenses | PAL-NUV-LC





- For bright field observation and laser processing
- Infinity corrected objective lens
- It can be used for 355nm
- Glass thickness is corrected to t=0.7mm or 1.1mm.
- magnification 20x,50x,100x
- With Plan-Apochromat
- Laser Damage Threshold (For reference only)
   (Laser pulse width 10ns, repetition frequency 20Hz)
   0.05 J/cm² (355nm)
   0.1 J/cm² (532nm)

## Glass Thickness Corrected Infrared Objective Lenses | PAL-NIR-LC





- $\bullet$  For bright field observation and laser processing
- Infinity corrected objective lens
- It can be used for 1064nm
- Glass thickness is corrected to t=0.7mm or 1.1mm.
- Magnification 20x,50x
- Laser Damage Threshold (For reference only)
  (Laser pulse width 10ns, repetition frequency 20Hz)
  0.1 J/cm² (532nm)
  0.2 J/cm² (1064 nm)

### Glass Thickness Corrected Infrared Objective Lenses | PAL-NIR (780)

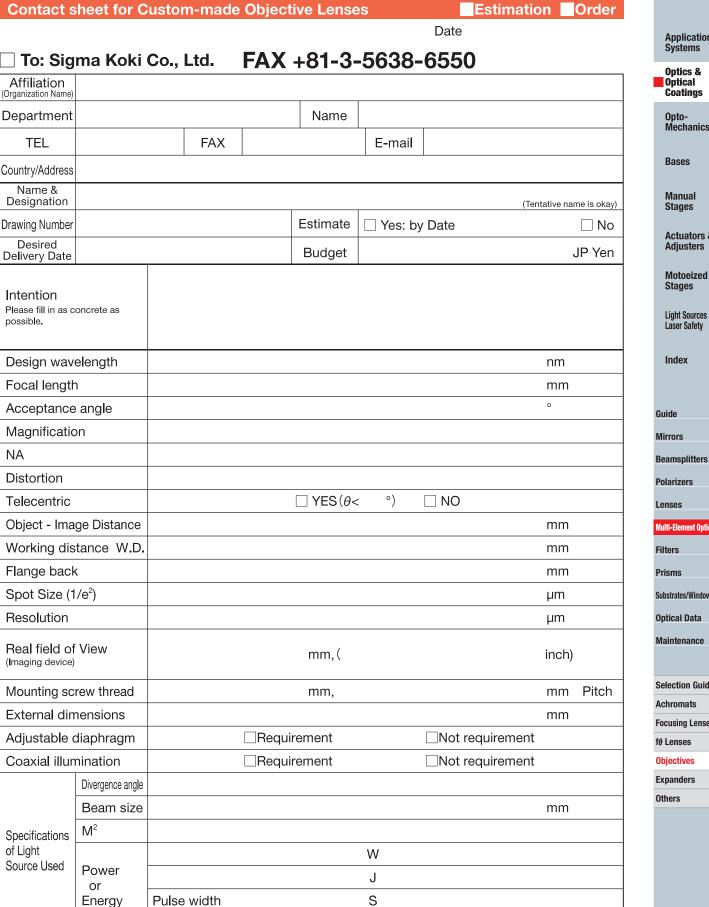




- Infinity corrected objective lens
- It can be used for 780nm
- Glass thickness is corrected to t=0.7mm
- Magnification 20x,50x
- Laser Damage Threshold (For reference only)
   (Laser pulse width 10ns, repetition frequency 20Hz)
   0.1 J/cm² (532nm)
   0.15 J/cm² (780nm)

## Contact sheet





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Sigma Koki Co., Ltd.

General Catalog 02

Hz

Repetition frequency